

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Appl. No. : 10/823,970) Confirmation No. 5318
Applicant : OGAWA, et al.)
Filed : 13 April 2004)
Art Unit : 2892)
Examiner : Hoang, Quoc Dinh)
Attorney :)
Docket No. : SPSN-AF01215)
)
For: SEMICONDUCTOR DEVICE HAVING)
A PAD METAL LAYER AND A LOWER METAL)
LAYER THAT ARE ELECTRICALLY)
COUPLED, WHEREAS APERTURES ARE)
FORMED IN THE LOWER METAL LAYER)
BELOW A CENTER AREA OF THE PAD)
METAL LAYER)
_____)

Honorable Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT AND RESPONSE TO OFFICE ACTION

Dear Sir:

In response to the final Office Action dated December 8, 2008, Applicants respectfully request reconsideration of the above-identified patent application. Please consider the following amendments and remarks for allowance of the above-identified patent application.

I hereby certify that this correspondence
is being electronically transmitted to the
USPTO via EFS on the date shown below:
December 16, 2008
/Christina Holland/
Christina Holland